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BY A p-n JUNCTION

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Discussion of some results obtained by Stafeev which show that, if the current-carrier mobility in a semiconductor is changed by an external effect, the relative change in the current ( $\Delta j/j$ ) flowing through a p-n junction with a thick base and the relative change in semiconductor conductivity ( $\Delta\sigma/\sigma$ ) are related by the expression  $\Delta j/j = K(\Delta\sigma/\sigma)$  where the amplification factor  $K$  is larger than unity. A formula for the maximum value of  $K$  is derived.

*Author*

It is generally known (Bibl.1) that, if any external effect changes the current-carrier mobility in a semiconductor, the relative change in the current  $\Delta f/f$  flowing through a p-n junction with a thick base ( $d/L \gg 1$ )\* built of this semiconductor and operating at a high level of injection will be connected with the relative change in the conductivity  $\Delta\sigma/\sigma$  of the semiconductor by the relation

$$\Delta f/f = K(\Delta\sigma/\sigma), \quad (1)$$

where  $K > 1$ . The latter fact ( $K > 1$ ) makes it possible to state that the p-n junction intensifies the effect of the external influence on the semiconductor, and to designate  $K$  as the amplification factor.

In another paper (Bibl.2)  $K$  was calculated for the case where the external

\* Notations as in an earlier report (Bibl.3). The calculations are performed in dimensional quantities.

\*\* Numbers in the margin indicate pagination in the original foreign text.

factor is a magnetic field. Under the assumptions that: 1) a magnetic field does not change the mobility ratio  $b$ ; 2) that  $\cosh(d/L) \gg b$ ; 3)  $N = 0$ ; 4) that  $\alpha(q/kT)v \gg 2b(d/L)e^{-d/L}$  we obtained the expression /196

$$\frac{J}{p} \approx \frac{1}{b} \frac{q}{kT} v \approx y \quad (2)$$

In itself, eq.(2), although valid within the framework of the assumptions used in deriving it, is insufficient for calculating  $K$  under actual conditions, in view of the fact that the values of  $d/L$  and  $\alpha v$ , as we will demonstrate, cannot be arbitrary.

First,  $d/L$  is bounded on top and, second, for any given  $d/L$ , also  $\alpha v$  has an upper bound while  $(\alpha v)_{max}$  depends on  $d/L$ . Thus, Karakushan (Bibl.2) solved only part of the problem of calculating  $K$ .

In this paper, we are making an attempt to calculate  $K$  in its final form. As had been done in the above paper (Bibl.2), we will assume that the external effect does not influence the value of  $b$ . It can be demonstrated that allowance for such an effect has only a slight influence on the final result. This is qualitatively clear from the fact that  $f$  depends bi-exponentially on  $d/L$  but less than exponentially on  $b$  [cf. eqs.(36) - (39), (Bibl.3)].

If the conductivity varies only on account of the variation in the mobility of the current carriers  $\mu$ , then

$$\Delta\sigma/\sigma = \Delta\mu/\mu \quad (3)$$

The relative variation in the current through a p-n junction is connected with the relative variation of the diffusion length by the relation

$$\frac{\Delta J}{J} = f\left(v, \frac{d}{L}\right) \frac{\Delta L}{L}, \quad (4)$$

where

$$f\left(v, \frac{d}{L}\right) = \left[ \alpha \frac{q}{kT} (v - \varphi_0) - \frac{b \ln \frac{1 + \cosh(d/L)}{2}}{b + \cosh(d/L)} - \frac{\cosh(d/L)}{1 + \cosh(d/L)} \right] \frac{\sinh(d/L)}{b + \cosh(d/L)} \frac{d}{L}; \quad (5)$$

$$\varphi_0 = \frac{kT}{q} \ln \left[ \left( 1 + \frac{b}{b+1} \frac{N}{P_n} \right) (1 + \gamma_0) \right]. \quad (6)$$

Equations (4) - (6) were obtained on the basis of eqs.(36) - (39) of another paper (Bibl.3). The relation between  $f_{s0}$  and  $L$  was not taken into account. It follows from the well-known relation  $L = \sqrt{(kT/q)\mu\tau}$  at  $\tau = \text{const}$  that

$$\frac{\Delta L}{L} = \frac{1}{2} \frac{\Delta \mu}{\mu} + \frac{1}{2} \frac{\Delta T}{T}. \quad (7)$$

When the external effect is a magnetic field, we have  $\Delta T = 0$  and from eqs.(3), (4), and (7) we obtain:

$$\frac{\Delta f}{f} = \frac{1}{2} f \left( v, \frac{d}{L} \right) \frac{\Delta \sigma}{\sigma}. \quad (8)$$

It is easy to see that  $f/2$  coincides with eq.(2) if the adopted assumptions (Bibl.2) are satisfied.

If the external action heats the gas of the current carriers [for example (Bibl.4)], then

$$\frac{\Delta \mu}{\mu} = \lambda \frac{\Delta T_0}{T_0}, \quad (9)$$

where  $\lambda$  is the exponent in the relation connecting  $\mu$  and  $T_0$  ( $T_0$  is the temperature of the current-carrier gas):  $\mu \sim T_0^\lambda$ . The value and sign of  $\lambda$  depend on the type of scattering. In lattice scattering, we have  $\lambda = -1/2$ , while in scattering on ionizing impurities,  $\lambda = 3/2$  (Bibl.5). Others adopt the semiempirical value  $\lambda \simeq 1$  (Bibl.4). Making use of eqs.(3), (4), (7), and (9), we get:

$$\frac{\Delta f}{f} = \frac{1}{2} \frac{\lambda+1}{\lambda} f \left( v, \frac{d}{L} \right) \frac{\Delta \sigma}{\sigma}. \quad (8a)$$

Comparison of eqs.(1), (8), and (8a) yields the conclusion that, in the general case,

$$K = \theta / (v, d/L), \quad (10)$$

where  $\theta \sim 1$  and  $f$  is determined in eq.(5).

Let us consider the limits within which  $\alpha v$ ,  $d/L$  and thus also  $K$  may vary. /197

The equation for the volt-ampere characteristic of the form (Bibl.3)

$$I = I_0(d/L) e^{(q/nT)\varphi} \quad (11)$$

and eq.(5) for  $f$ , obtained from eq.(11), are valid if (Bibl.3):

$$\gamma_0 \geq (1 + \gamma_d) \frac{1 + \cosh(d/L)}{2}, \quad (12)$$

where

$$\gamma_0 = \frac{(b+1)p_p e^{(q/nT)v_p}}{bN + (b+1)p_p}. \quad (13)$$

Since  $v_p$  cannot exceed the contact potential difference  $\varphi$ , the value of  $\gamma_0$  has an upper bound. If we set the maximum value of  $v_p$  at which eqs.(11) and (5) are still valid at

$$v_{p \max} = \varphi - \Delta, \quad (14)$$

where  $\Delta \sim (2-3)(kT/q)$  (Bibl.6) then we find from eqs.(12) - (14) and eq.(6) that  $d/L$  has an upper bound:  $d/L \leq (d/L)_{\max}$ . The value of  $(d/L)_{\max}$  is determined from the relation\*:

$$\ln \frac{1 + \cosh(d/L)_{\max}}{2} = \frac{q}{kT} (\varphi - \varphi_0 - 2\Delta). \quad (15)$$

The meaning of condition (15) is that a substantial modulation of the conductivity of the entire quasineutral region [in the sense of the criterion (12)] can be realized only at  $d/L \leq (d/L)_{\max}$ .

We pass next to an evaluation of the region of possible values of  $\alpha v$ . From eqs.(12) - (14) it follows that\*\*

$$\frac{q}{kT} (\varphi - \Delta) \geq \frac{q}{kT} v_p > \frac{q}{kT} \varphi_0 + \ln \frac{1 + \cosh(d/L)}{2}. \quad (16)$$

\* We replace the condition  $\geq$  by the sign of equality, multiplying the right-hand side of eq.(12) by  $e^{(q/kT)\Delta}$ .

\*\* In eq.(16) it was taken into consideration that, after taking the logarithms, the inequality  $\geq$  could be replaced by the less strict inequality  $>$ .

According to eqs.(35) and (37) in an earlier report (Bibl.3), we have

$$\frac{q}{kT} v_n = \frac{q}{kT} \alpha (v - \varphi_0) + \frac{q}{kT} \varphi_0 + \frac{\cosh(d/L)}{b + \cosh(d/L)} \ln \frac{1 + \cosh(d/L)}{2}. \quad (17)$$

Substituting eq.(17) into eq.(16), after a number of transformations and taking eq.(15) into account, we obtain

$$\begin{aligned} \frac{q}{kT} \Delta + \ln \frac{1 + \cosh(d/L)_{\max}}{2} - \frac{\cosh(d/L)}{b + \cosh(d/L)} \ln \frac{1 + \cosh(d/L)}{2} &> \frac{q}{kT} \alpha (v - \varphi_0) > \\ &> \frac{b}{b + \cosh(d/L)} \ln \frac{1 + \cosh(d/L)}{2}. \end{aligned} \quad (18)$$

Obviously, other conditions being equal, K will be greater the greater  $(q/kT)\alpha \cdot (v - \varphi)$ , so that  $K_{\max}$ , the maximum value of K for a given  $d/L$ , will be reached at

$$\left[ \frac{q}{kT} \alpha (v - \varphi_0) \right]_{\max} = \ln \frac{1 + \cosh(d/L)_{\max}}{2} - \frac{\cosh(d/L)}{b + \cosh(d/L)} \ln \frac{1 + \cosh(d/L)}{2} + \frac{q}{kT} \Delta. \quad (19)$$

Substituting eq.(19) into eq.(5), we get

$$K_{\max} = \theta \left[ \ln \frac{1 + \cosh(d/L)_{\max}}{1 + \cosh(d/L)} - \frac{\cosh(d/L)}{1 + \cosh(d/L)} + \frac{q}{kT} \Delta \right] \frac{\sinh(d/L)}{b + \cosh(d/L)} \frac{d}{L}. \quad (20)$$

As already noted, the case  $\cosh(d/L) \sim 1$  is not of interest here, and it is therefore natural to consider  $\cosh(d/L) \gg 1$ . As a result, it follows from eq.(20) that

$$K_{\max} \approx \theta \left[ \left( \frac{d}{L} \right)_{\max} - \frac{d}{L} + \frac{q}{kT} \Delta - 1 \right] \frac{e^{d/L}}{2b + e^{d/L}} \frac{d}{L}. \quad (20a)$$

It is obvious that the right-hand side of eq.(20a) has a maximum at some optimum value of  $d/L = (d/L)_{\text{opt}}$ , and that  $(d/L)_{\text{opt}} < (d/L)_{\max}$ . Calculation of  $(d/L)_{\text{opt}}$  and  $K_{\max \max} = K_{\max}[(d/L)_{\text{opt}}]$  for the case  $e^{(d/L)_{\text{opt}}} \gg b$  leads to the expressions

$$\left( \frac{d}{L} \right)_{\text{opt}} = \frac{1}{2} \left[ \left( \frac{d}{L} \right)_{\max} + \frac{q}{kT} \Delta - 1 \right], \quad (21)$$

$$K_{\max \max} = \theta (d/L)^2_{\text{opt}} \quad (22)$$

When the inequality  $e^{(d/L)_{\text{opt}}} \gg 2b$  is not satisfied (this case is possible in

p-n junctions of InSb, at  $b \gg 1$ ), the value of  $(d/L)_{opt}$  is shifted toward greater  $d/L$ .

It is clear from eqs.(21) and (22) that  $(d/L)_{opt}$  and  $K_{max}$  depend only on the ratio  $(d/L)_{max}$ , i.e., in the final analysis, on the degree of alloying of the p- and n-regions of the p-n junction. In fact, from eq.(15) at  $(d/L)_{max} \gg 1$  it follows that

$$\left(\frac{d}{L}\right)_{max} \simeq \frac{q}{kT} (\varphi - \varphi_0) - 2 \frac{q}{kT} \Delta + \ln 4 \quad (23)$$

Noting that  $\varphi = (kT/q) \ln(P/p_n)$  ( $P$  being the concentration of acceptors in the p-region) and bearing eq.(6) in mind, we obtain

$$\left(\frac{d}{L}\right)_{max} \simeq \ln \frac{(b+1)P}{bN + (b+1)p_n} - 2 \frac{q}{kT} \Delta - \ln \frac{1+\gamma_d}{4}, \quad (23a)$$

$$\left(\frac{d}{L}\right)_{opt} \simeq \frac{1}{2} \left[ \ln \frac{(b+1)P}{bN + (b+1)p_n} - \frac{q}{kT} \Delta - \ln \frac{1+\gamma_d}{4} - 1 \right]. \quad (21a)$$

Assume that  $\Delta \sim 3(kT/q)$  and  $\gamma_d \sim 1^*$ . In this case,

$$\left(\frac{d}{L}\right)_{opt} \simeq \frac{1}{2} \left[ \ln \frac{(b+1)P}{bN + (b+1)p_n} - 3 \right]. \quad (21b)$$

Obviously, the closer the conductivity of the n-region is to the intrinsic conductivity and the greater  $P^{**}$ , the greater will be  $(d/L)_{opt}$ . Let us estimate  $(d/L)_{opt}$  and  $K_{max}$  for actual cases.

The value of  $[bN + (b+1)p_n]$  in intrinsic germanium at room temperature is  $\sim 10^{13} \text{ cm}^{-3}$ . At lower temperatures (but higher than those corresponding to the freeze-out of the current carriers), this value is about  $10^{12} \text{ cm}^{-3}$ . At present, it is possible in InSb to reach a concentration of about  $10^{13} \text{ cm}^{-3}$ ,

\* The value of  $\gamma_d$  in the case  $d/L \gg 1$  is unknown. It may well be, however, that  $\gamma_d$  is less for  $d/L \gg 1$  than for  $d/L \ll 1$ . In the latter case, for  $N = 0$ , we would have  $\gamma_d \sim 10$  (Bibl.7).

\*\*  $P$  should not exceed the concentration corresponding to degeneration into p-regions.

which will remain constant down to helium temperatures. As for  $P$  in the cases of both Ge and InSb, we may assume  $P \sim 10^{18} \text{ cm}^{-3}$ . Thus we may consider, in our estimate, that  $(b + 1)P/[bN + (b + 1)p_n] \sim 10^5$ . Hence,  $(d/L)_{\text{opt}} \sim 4$  and  $K_{\text{max}} \sim 16 \theta$ .

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